

CLAIM AMENDMENTS:

1. (currently amended): A multilayered power supply line having a metal-insulator-metal structure, and comprising:

a first metal strip ~~that serves to serve~~ as a wiring metal;

a second metal strip located below the first metal strip; [[and]]

a third metal strip ~~that serves to serve~~ as a capacitor metal, said third metal strip being ~~located~~ sandwiched between the first metal strip and the second metal strip; and

an insulator embedded into gap portions defined among the first metal strip, the second metal strip, and the third metal strip;

wherein the first metal strip, the second metal strip, and the third metal strip are lengthwise mutually parallel;

~~wherein an insulator is embedded into gap portions defined among the first metal strip, the second metal strip, and the third metal strip,~~

wherein the second metal strip is electrically connected to the first metal strip and thereby supplied with power ~~identical~~ equal in potential to the first metal strip, and

wherein the first metal strip and the second metal strip are ~~identical~~ equal in wiring width.

2. (previously presented): The multilayered power supply line according to claim 1, wherein the second metal strip and the third metal strip are identical in

potential to each other and the third metal strip is electrically connected to the first metal strip.

3. (previously presented): The multilayered power supply line according to claim 2, wherein the first metal strip is supplied with a potential source of an external power supply, and the source potential of the external power supply is supplied even to the second metal strip and the third metal strip.

4. (previously presented): The multilayered power supply line according to claim 2, wherein the first metal strip is supplied with a ground potential, and the ground potential is supplied even to the second metal strip and the third metal strip.

5. (currently amended): The multilayered power supply line according to claim 1, which includes a plurality of strips comprised of the first metal strip, the second metal strip, and the third metal strip;

wherein some of the strips are supplied with a source potential of an [[the]] external power supply and others of the strips are supplied with a ground potential, wherein the source potential and the ground potential alternate in first metal strips which are disposed in a generally planar layer consisting of a plurality of the [[the]] first metal strip,

wherein the source potential and the ground potential alternate in adjacent strips of the first metal strip and the third metal strip, and

wherein the potential is similar in adjacent strips of the first metal strip and the second metal strip, whereby capacitors are configured by potential differences between the first metal strip and the second metal strip and between the first metal layer strip and the third metal strip.

6. (previously presented): The multilayered power supply line according to claim 5, further comprising:

a first 3-layer multilayered power supply line having a second metal strip supplied with the ground potential and a third metal strip supplied with the source potential of the external power supply, and

a second 3-layer multilayered power supply line having a second metal strip supplied with the source potential of the external power supply and a third metal strip supplied with the ground potential.

7. (previously presented): The multilayered power supply line according to claim 5, which includes, in the first metal strip, a capacitor made up of a parasitic capacitance developed between a metal strip supplied with the source potential of the external power supply and a metal strip supplied with the ground potential.

8-15. (canceled)

16. (previously presented): The multilayered power supply line according to claim 1, wherein the third metal strip has the same wiring width of the first metal strip and the second metal strip.

17. (previously presented): The multilayered power supply line according to claim 1, wherein the third metal strip is narrower than the wiring width of the first metal strip and the second metal strip.

18. (previously presented): The multilayered power supply line according to claim 5, wherein the third metal strip has the same wiring width of the first metal strip and the second metal strip.

19. (previously presented): The multilayered power supply line according to claim 5, wherein the third metal strip is narrower than the wiring width of the first metal strip and the second metal strip.

20. (previously presented): The multilayered power supply line according to claim 5, wherein the plurality of strips are mutually parallel and are arranged in a rectangular array.

21. (currently amended): A multilayered power supply line having a metal-insulator-metal structure, and consisting of:

a first metal strip ~~that serves to serve~~ as a wiring metal;

a second metal strip located below the first metal strip;

a third metal strip ~~that serves to serve~~ as a capacitor metal, said third metal strip being ~~located~~ sandwiched between the first metal strip and the second metal strip;

an insulator embedded into gap portions defined among the first metal strip, the second metal strip, and the third metal strip; and

electrical connections between the first and third metal strips and between the first and second metal strips;

wherein the first metal strip, the second metal strip, and the third metal strip are lengthwise mutually parallel. [[:]]

~~wherein an insulator is embedded into gap portions defined among the first metal strip, the second metal strip, and the third metal strip, and~~

~~wherein the second metal strip is electrically connected to the first metal strip and thereby supplied with power identical in potential to the first metal strip.~~

22. (currently amended): The multilayered power supply line according to claim 21, wherein the first metal strip and the second metal strip are identical equal in wiring width.

23. (currently amended): In combination, the multilayered power supply line according to claim 1 and at least one of a source potential connection of an external power supply and a ground potential connection connected ~~[[at]]~~ to at least one end of the multilayered power supply line, whereby electricity is conductable lengthwise through the multilayered power supply line.

24. (new): In combination, the multilayered power supply line according to claim 21 and at least one of a source potential connection of an external power supply and a ground potential connection connected to at least one end of the multilayered power supply line, whereby electricity is conductable lengthwise through the multilayered power supply line.

25. (new): A multilayered power supply line having a metal–insulator–metal structure, and comprising:

a first metal strip that serves as a wiring metal;

a second metal strip located below the first metal strip; and

a third metal strip that serves as a capacitor metal, said third metal strip being sandwiched in a gap between the first metal strip and the second metal strip;

wherein the first metal strip, the second metal strip, and the third metal strip are lengthwise mutually parallel;

wherein an insulator is embedded into gap portions defined among the first metal strip, the second metal strip, and the third metal strip,

wherein the second metal strip is electrically connected to the first metal strip by first conductive material in at least one longer through hole, the first conductive material being in direct contact with the first metal strip and the second metal strip, and

wherein the first metal strip is electrically connected to the third metal strip by second conductive material in at least one shorter through hole that is shorter than the longer through hole, the second conductive material being in direct contact with the first metal strip and the third metal strip,.